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Atty Docket No. OPE-023

Serial No. 10/627,043

Applicant

Geoff Taylor et al.

Filed July 25, 2003 Group 2828

## US PATENT DOCUMENTS

Examiner Initials		Document No.	Date	Name '	Class	Subclas	Filing date if approp.
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1	В	4,424,525	1/3/84	Mimura	357	23	
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